

Electronic Patent Application Fee Transmittal

Application Number:	10768611			
Filing Date:	29-Jan-2004			
Title of Invention:	Semiconductor device with nitrogen in oxide film on semiconductor substrate and method of manufacturing the same			
First Named Inventor:	Eiji Hasegawa			
Filer:	Max Moskowitz/Laura A. Cheung			
Attorney Docket Number:	P/29-1647			
Filed as Large Entity				
Utility Filing Fees				
Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Basic Filing:				
Pages:				
Claims:				
Claims in excess of 20	1202	1	50	50
Miscellaneous-Filing:				
Petition:				
Patent-Appeals-and-Interference:				
Post-Allowance-and-Post-Issuance:				
Extension-of-Time:				

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Miscellaneous:				
Request for continued examination	1801	1	790	790
Total in USD (\$)				840